L Number	Hits		DB	Time stamp
18	2	("5415754").PN.	USPAT;	2003/02/28 09:49
			EPO; JPO;	
			DERWENT	
-	1647	magnetic adj shunt	USPAT;	2003/02/28 08:56
			EPO; JPO;	
			DERWENT	
•	19	(magnetic adj shunt) and 250/\$.ccls.	USPAT;	2003/02/26 13:01
			EPO; JPO;	
			DERWENT	
-	92	(magnetic adj shunt) and optic\$5	USPAT:	2003/02/28 09:49
			EPO; JPO;	
	1		DERWENT	
-	902	shunt and 250/\$.ccls.	USPAT;	2003/02/26 13:02
			EPO; JPO;	2005/02/20 15:02
			DERWENT	
	224	(shunt and 250/\$.ccls.) and magnetic	USPAT;	2002/02/24 12:02
-	224	(Shuff and 250/5.ccis.) and magnetic	1 '	2003/02/26 13:02
			EPO; JPO;	
		((1 , 10,000 1) 1 , 2) 1 ()	DERWENT	
•	113	((shunt and 250/\$.ccls.) and magnetic) and (stage wafer)	USPAT;	2003/02/26 13:09
			EPO; JPO;	
			DERWENT	
-	208	magnetic adj shunt same (stage hold\$4 wafer substrate base)	USPAT;	2003/02/26 14:43
			EPO; JPO;	
			DERWENT	
-	14	(magnetic adj shunt same (stage hold\$4 wafer substrate base) same	USPAT;	2003/02/26 14:45
		(mov\$4 translat\$4 position\$4)) and optic\$4	EPO; JPO;	
		(,	DERWENT	
_	106	magnetic adj shunt same (stage hold\$4 wafer substrate base) same	USPAT;	2003/02/26 15:29
	100	(mov\$4 translat\$4 position\$4)	EPO; JPO;	2003/02/20 13.23
		(movor transauor positionor)	DERWENT	
	66272	magnetic same (stage hold\$4 wafer substrate base) same (mov\$4	1	2002/02/26 15.21
-	00272		USPAT;	2003/02/26 15:31
		translat\$4 position\$4)	EPO; JPO;	
-	12101		DERWENT	
	43181	magnetic same (mov\$4 translat\$4 position\$4) with (stage hold\$4 wafer	USPAT;	2003/02/26 15:41
		substrate base)	EPO; JPO;	
			DERWENT	
•	1216	(magnetic same (mov\$4 translat\$4 position\$4) with (stage hold\$4 wafer	USPAT;	2003/02/26 15:42
		substrate base)) and permeable	EPO; JPO;	
			DERWENT	
-	337	((magnetic same (mov\$4 translat\$4 position\$4) with (stage hold\$4 wafer	USPAT;	2003/02/26 15:47
	1	substrate base) and permeable) and (optic\$ illuminat\$5)	EPO; JPO;	1
			DERWENT	
-	43	(((magnetic same (mov\$4 translat\$4 position\$4) with (stage hold\$4 wafer	USPAT;	2003/02/26 16:17
		substrate base) and permeable) and (optic\$ illuminat\$5)) and 250/\$.ccls.	EPO; JPO;	
		Coping manager, and Coping manager, and about the	DERWENT	
-	18	(("4310764") or ("4465934") or ("4607167") or ("4628466") or	USPAT;	2003/02/26 16:18
	10	("4866280") or ("4985634") or ("5446722") or ("6285097")).PN.	1	2003/02/20 10.10
		(4000200) 01 (4703034) 01 (3440722) 01 (0203077)).PN.	EPO; JPO;	
		((HA2107(AB) (HAA6502AB) (HA607167B) (HA629A66B)	DERWENT	2002/02/2016
-	8	(("4310764") or ("4465934") or ("4607167") or ("4628466") or	USPAT	2003/02/26 16:18
		("4866280") or ("4985634") or ("5446722") or ("6285097")).PN.		
-	8	((("4310764") or ("4465934") or ("4607167") or ("4628466") or	USPAT;	2003/02/27 08:06
		("4866280") or ("4985634") or ("5446722") or ("6285097")).PN.) and	EPO; JPO;	
		magnet\$4	DERWENT	
	3	(("4444643") or ("4714536") or ("5320728")).PN.	USPAT	2003/02/27 08:08
-	310	magnetic adj shunt.clm.	USPAT;	2003/02/27 08:09
		ž ž	EPO; JPO;	
			DERWENT	
-	3148085	(magnetic adj shunt.clm.) and stage wafer base	USPAT;	2003/02/27 08:09
	3140003	(magnetic auf shunt.cini.) and stage water base	EPO: JPO:	2003/02/2/ 00.0
			, , ,	
			DERWENT	2002/02/27 02 0
	141	(magnetic adj shunt.clm.) and (stage wafer base)	USPAT;	2003/02/27 08 09
			EPO; JPO;	
	I	1	DERWENT	1